

	Hits	Search Text	DBs
39	1	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near9 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and ((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
40	1	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near29 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and ((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

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41	1	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near29 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4 or photolithograph\$6) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
42	1	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near29 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
43	2	(((photosensitive or (light near6 sensitiv\$5)) near29 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hit s	Search Text	DBs
44	1	(capacitor or device) and (((photosensitive or (light near6 sensitiv\$5)) near9 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2 or air or oxygen) same (hard near6 mask\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
45	29	((capacitor or device) same (((photosensitive or (light near6 sensitiv\$5)) near9 sol\$3gel) or ((titanium or Ti) near7 sol\$3gel) or (Ti\$2Al near5 organic near4 gel) or (titanium near3 alumin\$3 near4 sol\$3gel)))) and (((photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) or pattern\$4) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2 or air or oxygen))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB

	Hits	Search Text	DBs
46	29	((capacitor or device) same (sol\$3gel or ((titanium or Ti) near28 sol\$3gel) or (Ti\$2Al near19 organic near6 gel) or (titanium near3 alumin\$3 near18 sol\$3gel)) same (photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3)) and (((thermal\$3 near5 (decompos\$5 or treat\$5)) or heat\$4 or bak\$4) same (nitrogen\$4 or N\$2))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB
47	3	((("20030119273") or ("20040164293") or ("6566276"))).PN.	US-PGPUB; USPAT
48	4	((hard near15 mask) same (sol\$3gel or ((titanium or Ti) near28 sol\$3gel) or (Ti\$2Al near19 organic near6 gel) or (titanium near3 alumin\$3 near18 sol\$3gel)) same (photoresist or resist or photo\$3cur\$4 or (radiation near5 sensitive)) same (pattern\$3 or expos\$3 or illuminat\$3 or irradiat\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB